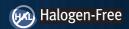
EPC2040 – Enhancement Mode Power Transistor

 V_{DSS} , 15 V $R_{DS(on)}$, $30 \, \text{m}\Omega$ I_D , 3.4 A









Gallium Nitride is grown on Silicon Wafers and processed using standard CMOS equipment leveraging the infrastructure that has been developed over the last 60 years. GaN's exceptionally $high\ electron\ mobility\ and\ low\ temperature\ coefficient\ allows\ very\ low\ R_{DS(on)},\ while\ its\ lateral\ device$ structure and majority carrier diode provide exceptionally low Q_G and zero Q_{RR} . The end result is a device that can handle tasks where very high switching frequency, and low on-time are beneficial as well as those where on-state losses dominate.

| | Maximum Ratings | | | | | |
|-----------------|---|------------|----|--|--|--|
| V_{DS} | Drain-to-Source Voltage (Continuous) | 15 | V | | | |
| - 03 | Drain-to-Source Voltage (up to 10,000 5ms pulses at 150°C) | 18 | | | | |
| I _D | Continuous ($T_A = 25^{\circ}C$, $R_{\theta JA} = 220^{\circ}C/W$) | 3.4 | А | | | |
| | Pulsed (25°C, T _{PULSE} = 300 μs) | 28 | | | | |
| V | Gate-to-Source Voltage | 6 | V | | | |
| V _{GS} | Gate-to-Source Voltage | -4 | V | | | |
| TJ | Operating Temperature | -40 to 150 | °C | | | |
| T_{STG} | Storage Temperature | -40 to 150 | | | | |



EPC2040 eGaN® FETs are supplied only in passivated die form with solder bumps Die Size: 0.85 mm x 1.25 mm

Applications

- High Speed DC-DC conversion
- LiDAR/Pulsed Power Applications
- LiDAR for Augmented Reality Applications

Benefits

- · Ultra High Efficiency
- Ultra Low R_{DS(on)}
- Ultra low Q_G
- · Ultra small footprint

www.epc-co.com/epc/Products/eGaNFETs/EPC2040.aspx

| Static Characteristics (T _j = 25°C unless otherwise stated) | | | | | | |
|--|--------------------------------|---|-----|-----|-----|-------|
| PARAMETER | | TEST CONDITIONS MIN | | ТҮР | MAX | UNIT |
| BV _{DSS} | Drain-to-Source Voltage | $V_{GS} = 0 \text{ V, } I_D = 300 \mu\text{A}$ | 15 | | | V |
| I _{DSS} | Drain Source Leakage | $V_{DS} = 12 \text{ V}, V_{GS} = 0 \text{ V}$ | | 10 | 250 | μΑ |
| | Gate-to-Source Forward Leakage | $V_{GS} = 5 V$ | | 0.1 | 1.2 | mA |
| I _{GSS} | Gate-to-Source Reverse Leakage | $V_{GS} = -4 V$ | | 10 | 250 | μΑ |
| $V_{GS(TH)}$ | Gate Threshold Voltage | $V_{DS} = V_{GS}$, $I_D = 1 \text{ mA}$ | 0.8 | 1.4 | 2.5 | V |
| R _{DS(on)} | Drain-Source On Resistance | $V_{GS} = 5 \text{ V}, I_D = 1.5 \text{ A}$ | | 24 | 30 | m $Ω$ |
| V _{SD} | Source-Drain Forward Voltage | $I_S = 0.5 \text{ A}, V_{GS} = 0 \text{ V}$ | | 2.2 | | V |

All measurements were done with substrate shorted to source.

| Thermal Characteristics | | | | |
|-------------------------|--|-----|------|--|
| | | ТҮР | UNIT | |
| $R_{	heta JC}$ | Thermal Resistance, Junction to Case | 5.7 | °C/W | |
| $R_{\theta JB}$ | Thermal Resistance, Junction to Board | 19 | °C/W | |
| $R_{\theta JA}$ | Thermal Resistance, Junction to Ambient (Note 1) | 97 | °C/W | |

Note 1: R_{8,M} is determined with the device mounted on one square inch of copper pad, single layer 2 oz copper on FR4 board. See http://epc-co.com/epc/documents/product-training/Appnote_Thermal_Performance_of_eGaN_FETs.pdf for details.

| | Dynamic Characteristics (T _J = 25°C unless otherwise stated) | | | | | |
|----------------------|--|---|-----|-----|-----|------------|
| PARAMETER | | TEST CONDITIONS | MIN | TYP | MAX | UNIT |
| C _{ISS} | Input Capacitance | | | 86 | 105 | |
| C _{RSS} | Reverse Transfer Capacitance | $V_{DS} = 6 \text{ V}, V_{GS} = 0 \text{ V}$ | | 20 | | |
| Coss | Output Capacitance | | | 67 | 100 | pF |
| C _{OSS(ER)} | Effective Output Capacitance, Energy Related (Note 2) | $V_{DS} = 0 \text{ to } 6 \text{ V, } V_{GS} = 0 \text{ V}$ | | 106 | | |
| C _{OSS(TR)} | Effective Output Capacitance, Time Related (Note 3) | ν _{DS} = 0 t0 0 ν, ν _{GS} = 0 ν | | 87 | | |
| R_{G} | Gate Resistance | | | 0.5 | | Ω |
| Q_{G} | Total Gate Charge | $V_{DS} = 6 \text{ V}, V_{GS} = 5 \text{ V}, I_{D} = 1.5 \text{ A}$ | | 745 | 925 | |
| Q_{GS} | Gate to Source Charge | | | 230 | | |
| Q_{GD} | Gate to Drain Charge | $V_{DS} = 6 \text{ V}, I_{D} = 1.5 \text{ A}$ | | 140 | | " C |
| $Q_{G(TH)}$ | Gate Charge at Threshold | | | 165 | | рС |
| Qoss | Output Charge | $V_{DS} = 6 \text{ V}, V_{GS} = 0 \text{ V}$ | | 420 | 630 | |
| Q_{RR} | Source-Drain Recovery Charge | | · | 0 | | |

Note 2: $C_{OSS(RR)}$ is a fixed capacitance that gives the same stored energy as C_{oss} while V_{DS} is rising from 0 to 40% BV_{DSS}. Note 3: $C_{OSS(RR)}$ is a fixed capacitance that gives the same charging time as C_{oss} while V_{DS} is rising from 0 to 40% BV_{DSS}.

Figure 1: Typical Output Characteristics at 25°C

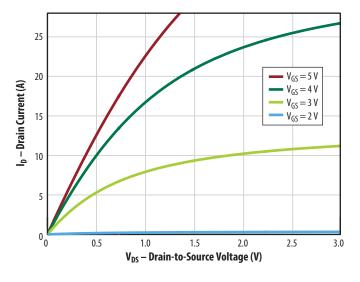


Figure 3: $R_{DS(on)}$ vs. V_{GS} for Various Drain Currents

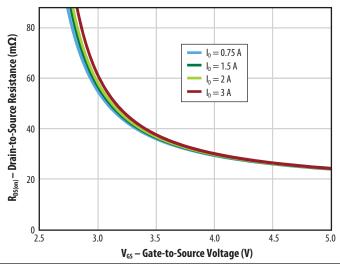


Figure 2: Transfer Characteristics

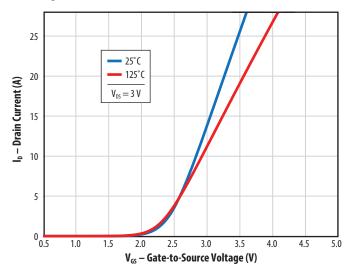


Figure 4: $R_{DS(on)}$ vs. V_{GS} for Various Temperatures

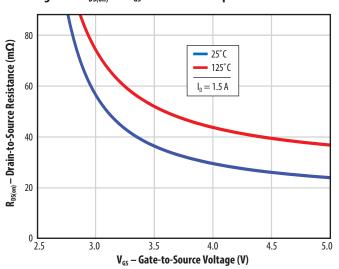


Figure 5a: Capacitance (Linear Scale)

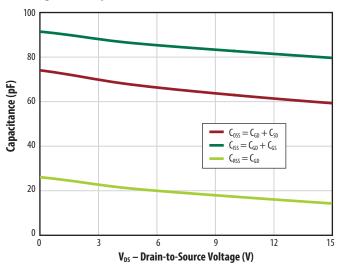


Figure 5b: Capacitance (Log Scale)

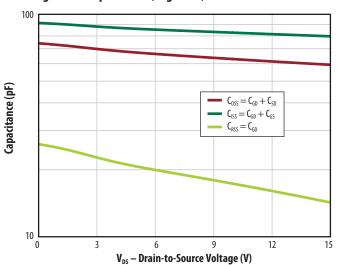


Figure 6: Gate Charge

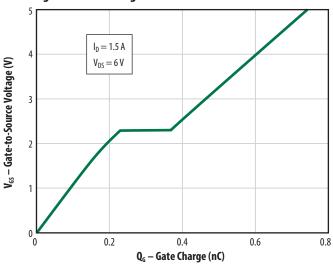


Figure 7: Reverse Drain-Source Characteristics

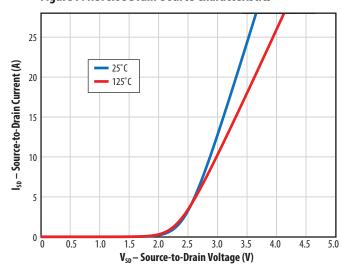


Figure 8: Normalized On-State Resistance vs. Temperature

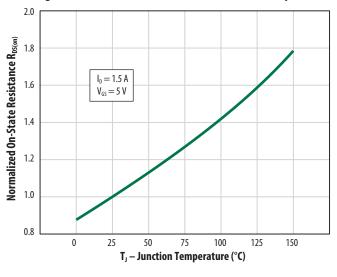
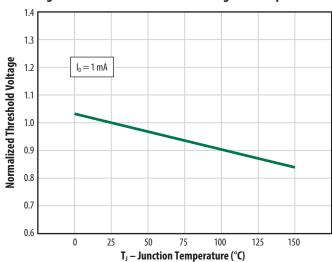


Figure 9: Normalized Threshold Voltage vs. Temperature



All measurements were done with substrate shortened to source

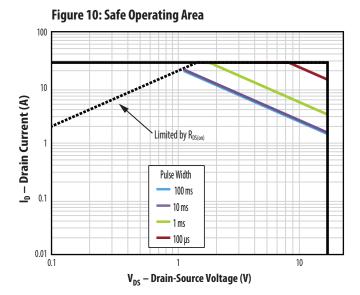
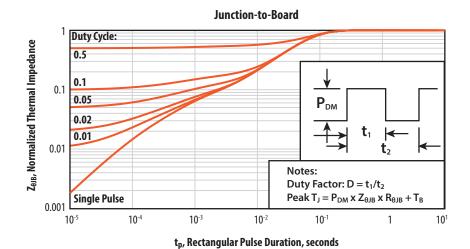
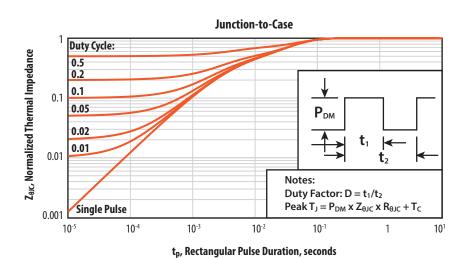
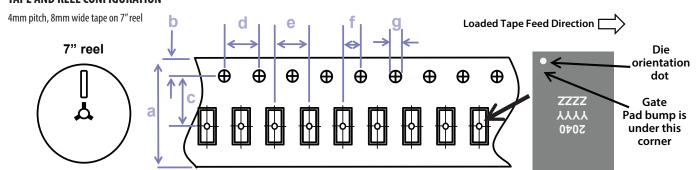


Figure 11: Transient Thermal Response Curves





TAPE AND REEL CONFIGURATION



| | EPC2040 (note 1) | | |
|----------------|------------------|------|------|
| Dimension (mm) | target | min | max |
| а | 8.00 | 7.90 | 8.30 |
| b | 1.75 | 1.65 | 1.85 |
| c (see note) | 3.50 | 3.45 | 3.55 |
| d | 4.00 | 3.90 | 4.10 |
| е | 4.00 | 3.90 | 4.10 |
| f (see note) | 2.00 | 1.95 | 2.05 |
| g | 1.5 | 1.5 | 1.6 |

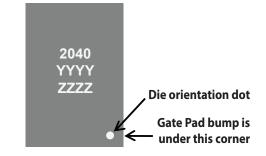
Die is placed into pocket bump side down (face side down)

Note 1: MSL 1 (moisture sensitivity level 1) classified according to IPC/JEDEC industry standard.

Note 2: Pocket position is relative to the sprocket hole measured as true position of the pocket, not the pocket hole.

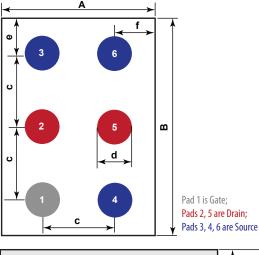
DIE MARKINGS

| Part | Laser M | arkings | |
|---------|--------------------------|---------------------------------|---------------------------------|
| Number | Part # Marking Line 1 | Lot_Date Code Marking line 2 | Lot_Date Code Marking line 3 |
| EPC2040 | 2040 | YYYY | ZZZZ |



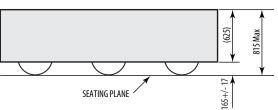
DIE OUTLINE

Solder Bump View



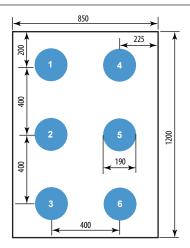
| | Micrometers | | | |
|-----|-------------|---------|------|--|
| DIM | MIN | Nominal | MAX | |
| Α | 820 | 850 | 880 | |
| В | 1170 | 1200 | 1230 | |
| С | | 400 | | |
| d | 187 | 208 | 229 | |
| e | 185 | 200 | 215 | |
| f | 210 | 225 | 240 | |

Side View



RECOMMENDED LAND PATTERN

(measurements in μ m)



The land pattern is solder mask defined Solder mask is 10 µm smaller per side than bump

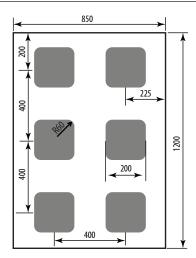
Pad 1 is Gate;

Pads 2, 5 are Drain;

Pads 3, 4, 6 are Source

RECOMMENDED STENCIL DRAWING

(measurements in μ m)



Recommended stencil should be 4mil (100 μ m) thick, must be laser cut, openings per drawing.

Intended for use with SAC305 Type 4 solder, reference 88.5% metals content.

Additional assembly resources available at

http://epc-co.com/epc/DesignSupport/AssemblyBasics.aspx

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